## **Supporting Information for**

## Novel polyamides with fluorene-based triphenylamine: electrofluorescence and electrochromic properties

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Fig. S1 IR spectra of dinitro intermediate compound (a) and diamine monomer (b).



Fig. S2 IR spectrum of polyamide 4a.



**Fig. S3** IR spectra of polyamide 4b, 4c, 4d, 4e.



**Fig. S4** H-H COSY spectra of diamine 2 in DMSO-*d*<sub>6</sub>.



**Fig. S5** <sup>1</sup>H NMR spectra of the polyamide 4a, 4b, 4d, 4e in DMSO-*d*<sub>6</sub>.



Fig. S6 WAXD pattern of polyamide films.



Fig. S7 UV-vis absorption spectra of polyamides (a) solution and (b) film.



Fig. S8 PL spectra of polyamides in NMP solutions  $(1 \times 10^{-5} \text{ M})$ .



Fig. S9 Calculated molecular orbitals of the model compounds (TD-DFT method at the B3LYP/6-31G (d, p)).



**Fig. S10** Cyclic voltammetric diagrams of polyamide (a) 4a, (b) 4b, (c) 4d, (d) 4e in CH<sub>3</sub>CN containing 0.1M TBAP at scan rate= 50 mV s<sup>-1</sup>.



**Fig. S11** Calculation of optical switching time at 860nm at the applied potential of polyamide 4c thin film on the ITO-coated glass substrate in 0.1 M TBAP/CH<sub>3</sub>CN.